

Application/Control No.	Applicant(s)/Patent under Reexamination	''	
10/738,411	MCKIE ET AL.		
Examiner	Art Unit		
Shengjun Wang	1617		

	SEARCHED					
Class	Subclass	Date	Examiner			
514	160	6/8/2007	sw			
		-				

INTERFERENCE SEARCHED					
Class	Subclass	Date	Examiner		
		······································			
		· · · · · · · · · · · · · · · · · ·			
			•		

SEARCH NOTES (INCLUDING SEARCH STRATEGY)				
	DATE	EXMR		
CAPLUS, MEDLINE, BIOSIS, EMBASE	6/8/2007	sw		
salicylic acid, chlorosalicylic acid, halogenated salicylic acid, acne, pore size, sebum, retinoid, phytol, finasteride.				
inventor search	6/8/2007	SW		